

May 18 – May 20, 2009 http://www.ICICDT.org

Freescale Semiconductor 7700 W Parmer Lane, Austin, TX 78729



### **Conference Vision**

Global collaboration among professionals engaged in the multi-disciplinary fields of advanced IC design, device design, design tools/technology and process technology development enables accelerated product time-to-market, particularly for high-performance products which incorporate advanced management of power, leakage, device degradation and yield.

### **Conference overview**

ICICDT provides a forum for engineers, researchers, scientists, professors and students to explore the interactions of design and process technology on product / IC development & manufacturing. The unique workshop style of the conference and the unusual opportunity for technologists and product designers to interact enables the exchange of breakthrough ideas and creative collaboration. Two days of technical presentations and workshops will be preceded by a one-day tutorial program of value to both the expert and the beginner.

Close collaboration amongst professionals in the multi-disciplinary technical fields - design/device/process - accelerates the implementation of new designs and new technologies into manufacturing. The separation of system/IC design and manufacturing in the semiconductor industry - leading to the emergence of specialized fabless design houses, wafer foundries, design automation tool/software companies, and semiconductor processing tool suppliers - creates a need for collaboration among individuals with technical skills across these multiple fields. Further, advanced IC technology can no longer offer the same level of control as earlier over many parameters that

have a direct adverse impact on circuit behavior. New IC designs also push the limit of technology, and in some cases, require specific fine-tuning of certain process modules in manufacturing.

Thus the communities of design and technology are increasingly intertwined. The issues which require close interaction and collaboration for trade-off and optimization across the design/device/process fields are addressed in this conference. Hence, this conference is organized in a single session format (with no parallel sessions) with 58 invited and contributed talks, to provide opportunities for a direct interaction among the attendees and presenters, to participate in discussions across multiple disciplines of design/device/process issues during the two days of 14 plenary & workshop sessions. Each session is organized with short oral presentations followed by a one-hour workshop to facilitate interactive discussion of questions & answers. In addition, on the first day, five indepth tutorial courses have been organized.

### Who Should Attend?

This conference is intended for IC design, circuit, device, process, integration, and reliability engineers and managers working to accelerate the product time-to-market through the implementation of new designs and new technologies into manufacturing, including the design and development of advanced devices and materials, and IC and device reliability.

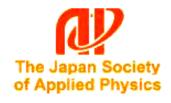
### **Conference Venue**

The venue for the 2009 Conference is Freescale Semiconductor at Austin, Texas, U.S.A.











IEEE Circuits and Systems Society

May 18 - May 20, 2009, Freescale Semiconductor, Austin, TX, U.S.A.; http://www.ICICDT.org

### Committee Members

- Amara Amara, ISEP (General Chair)
- ➤ Koji Eriguchi, Kyoto University (Conference Chair)
- > Tanay Karnik, Intel (Conference Past Chair)
- ➤ Marc Belleville, LETI (2010 Chair elected)
- Chua-Chin Wang, National Sun Yat-Sen University (2011 Chair elected, I/O Circuits and ESD Protection Chair)
- ➤ Thuy Dao, Freescale Semiconductor (Conference Executive Committee Chair, IEEE ED CTS Chair)
- ➤ Dina Triyoso, Freescale Semiconductor (Conference Treasurer, IEEE ED CTS Vice Chair)
- ➤ Jean-Luc Leray, CEA (Conference Secretary)
- ➤ Thomas Ea, ISEP (Publication chair)
- ➤ Terrence Hook, IBM (Publicity Chair)
- Chris Kim, University of Minnesota (Tutorials Chair)
- ➤ Ali Keshavarzi, TSMC (Tutorials Chair)
- David Pan, University of Texas at Austin (Award Chair)
- ➤ Dac Pham, Freescale Semiconductor (Local Arrangements Chair, SOC Chair)
- Aurangzeb Khan, Everspin, Inc. (SOC Chair)
- > Toshinari Takayanagi, Apple (Low Power Chair)
- ➤ Geoffrey Yeap, Qualcomm (Low Power Chair)
- ➤ Jan Ackaert, On Semiconductor (High Power Devices Chair)
- Susumu Shuto, Toshiba Corporation (Advanced Memory Devices Chair)
- Hideto Hidaka, Renesas (Advanced Memory Devices Chair)
- Yuuichiro Mitani, Toshiba Corporation (PID/Reliability Chair)
- ➤ Keith Bowman, Intel (DFM/DFT/DFR/DFY Chair)
- Ruchir Puri, IBM (CAD Chair)
- Dong-Won Kim, Samsung Electronics (Advanced Transistors Chair)
- Arnaud Pouydebasque, CEA (Advanced Transistors Chair)

- Phillip Christie, NXP Semiconductor (Technology Pathfinding Chair)
- ➤ Didier Berlot, STMicroelectronic (RF/Analog Chair)
- Andrea Mazzanti, Universita di Modena e Reggio (RF/ Analog Chair)
- Ming-Dou (Morris) Ker, I-Shou University (I/O Circuits and ESD Protection Chair)
- ➤ Eishi Ibe, Hitachi (SER Chair)
- ➤ Simon Deleonibus, CEA (Emerging Technologies)
- ➤ Garrett Polhamus, SWBell (IEEE CTS Chair)
- ➤ Andrea Scarpa, NXP Semiconductors
- > Atsuki Inoue, Fujitsu
- > Bart Keppens, Sarnoff Europe
- ➤ Bich-Yen Nguyen, Soitec
- > Charles Slayman, Sun Microsystems
- David Duarte, Intel
- ➤ David Tremouilles, LAAS/CNRS
- ➤ Himansu Arora, Duke University
- > Ingo Aller, IBM
- > Jason Stinson, Intel
- > John Robertson, Cambridge University
- ➤ Kin P. (Charles) Cheung, NIST
- ➤ Linten Dimitri, IMEC
- > Manfred Engelhardt, Oimonda
- Masaya Sumita, Panasonic
- Nobuyuki Mise, Hitachi
- Paul Tong, Pericom Semiconductor
- > Philippe Royannez, TI
- Prashant Majhi, SEMATECH
- Rouwaida Kanj, IBM
- > Salvatore Lombardo, IMM of the CNR
- Shrikanth Krishnan, TI
- ➤ Shui-Ming Cheng, TSMC
- > Toshiro Hiramoto, University of Tokyo
- Veronique Ferlet, CEA
- ➤ Ya-Hsin Hsueh, National Yunlin University of Science and Technology

May 18 - May 20, 2009, Freescale Semiconductor, Austin, TX, U.S.A.; http://www.ICICDT.org

### **ICICDT Tutorials**

### Tutorial Chair: Prof. Chris H. Kim, University of Minnesota

## May 18, 2009

## "Technology-Circuit-Architecture Optimization for Energy Efficient Integrated Systems"

## Tutorial Chair: Prof. Chris H. Kim, University of Minnesota

On this first day of ICICDT, five in-depth tutorial courses have been organized, to provide a head-start learning opportunity in IC design & technology. This year's tutorial will discuss the interaction between technology, circuit, and architecture for designing robust energy efficient integrated systems. With Moore's law approaching its limit and the mounting pressure to deliver new products with advanced features, such interaction between different levels of design abstraction is becoming indispensible. Topics will range from advanced memory circuits and wireless transceivers to VLSI signal processing for medical/communication applications and mixed-signal I/Os. Specific design examples will be presented to highlight real world implications. This tutorial is targeted for both experienced researchers and a general engineering audience.

08:30 a.m. 09:00 a.m.

### **Registration & Breakfast (Included)**

Technology, Circuits, and Systems: Can't We All Just Get Along?

**Presenter: Dr. Leland Chang**, IBM TJ

Watson Research Center

As challenges mount in the **Abstract:** continued advancement of microelectronics, a broad perspective is needed to assess the tradeoffs involved in overcoming circumventing current limits to CMOS technology scaling. Device technologists, circuit designers, and systems architects can no longer focus solely on their own realms of expertise, but must also understand the issues faced by the other communities to achieve an overarching goal of robust, high-performance, and power-efficient computing systems. In this tutorial, specific examples of such interaction will be cited from recent areas of research, including new materials and device structures, embedded memory scaling and bandwidth, and overall system power efficiency. Future research directions will be discussed, with a particular emphasis on the search for post-CMOS device options, which further underscores the need to assess benefits and tradeoffs across technology, circuits, and systems perspectives.

Bio: Leland Chang received the B. S., M. S., and Ph.D. degrees in electrical engineering and computer sciences from the University of California, Berkeley and joined the IBM T. J. Watson Research Center in 2003, where he is now Manager of Design and Technology Solutions. His early research focused on pioneering work in ultra-thin body and doublegate MOSFETs for CMOS scaling, including fabrication of the FinFET double-gate structure down to record gate lengths. More recently, he has pursued SRAM scaling issues, which has resulted in the demonstration of SRAM cells down to record sizes and the proposal and demonstration of 8T-SRAM for variability tolerance and low voltage operation. His current work focuses on interactions between technology and circuit design, with a particular emphasis on embedded memory and power efficiency. He holds 9 patents and has authored more than 45 technical articles.

10:15 a.m. 10:30 a.m.

Coffee Break
Design of Ultra-Low Power Transceivers for
Wireless Sensors

**Presenter: Prof. Brian Otis**, University of Washington

**Abstract:** Emerging applications of wireless sensors require new levels of system integration, functionality, and lifetime. Body area networks, implantable devices, and small animal tracking research are a few examples that will be discussed. These applications place increasingly severe demands on RFIC designers. Miniaturization and power concerns, already important considerations in portable radio design, are amplified in these emerging wireless sensor applications. Additionally, there are several needs on the horizon that will demand completely thin-film integration of RF

May 18 - May 20, 2009, Freescale Semiconductor, Austin, TX, U.S.A.; <a href="http://www.ICICDT.org">http://www.ICICDT.org</a>

transceivers, prohibiting surface-mount components of any kind. This talk will discuss various RF transceiver design techniques, including miniaturized MEMS-based radios, frequency-multiplying transceiver architectures, and wirelessly-powered sensor data links. Test chip architectures will be presented and measured results described.

Bio: Brian Otis received the B.S. degree in electrical engineering from the University of Washington and the M.S. and Ph.D. degrees from the University of California at Berkeley. He joined the faculty of the University of Washington as Assistant Professor of Electrical Engineering in August 2005. His primary research interests are ultra-low power RFIC design and bioelectrical interface circuits and systems. He has previously held positions at Intel Corporation and Agilent Technologies. Dr. Otis is an Associate Editor of the IEEE Transactions on Circuits and Systems Part II. He was the recipient of the 2003 U.C. Berkeley Seven Rosen Funds award for innovation and was co-recipient of the 2002 ISSCC Jack Raper Award for Outstanding Technology Directions Paper.

11: 45 p.m. 01: 00 p.m.

Lunch

Low-power VLSI Signal Processing for Medical and Communication Systems

**Presenter:** Manish Goel, Texas Instruments

Abstract: In this talk, we will present lowpower signal processing techniques used in energy-constrained medical applications and high data-rate wireless communication systems. For the wireless communication systems, we will discuss two OFDM systems including terrestrial digital TV DVB-H receiver and nextgeneration LTE wireless cellular modem. We will look at the trade-offs between flexibility and power consumption for physical layer signal processing including implementation trade-offs for a few components such as FFT, MIMO decoder and forward error correction decoder. For medical applications, we will consider a system built around an ultra lowpower 16-bit microcontroller platform and show trade-offs for choosing the optimum design parameters such as flexibility, parallelism, clock frequency and voltage. For this application, implementation trade-offs for common building blocks such as FFT and filtering will be considered.

Bio: Manish Goel joined Texas Instruments in 2000 and holds position of senior member of technical staff in Signal Processing systems R&D center at Texas Instruments. Manish's research interests are in low-power, signal processing, wireless communication and medical systems. Manish has led and contributed to several wireless R&D efforts at TI including mobile digital TV receiver, 4G WiMAX/LTE modem, multi-antenna wireless LAN and fixed-wireless access. He is currently managing an R&D team involved in low-power signal processing VLSI for medical and communication applications. Manish received his bachelor's degree from India Institute of technology in Delhi, and a master's degree and Ph.D. from the University of Illinois at Urbana-Champaign.

02: 30 p.m. Integrated Sensors for Measuring Noise Processes in Modern Microprocessors

**Presenter:** Alan Drake, IBM Austin Research Labs

Noise is the enemy of Abstract: efficiency. Within the complexity of modern microprocessors are the seeds of the noise that increase timing margins and that reduce efficiency. Microprocessors are a marvel of integration with a mix of processing cores and support circuitry, but shifting workloads between cores coupled with process variation and other environmental factors increases timing noise and hence the margin. Much work has been done to improve microprocessor efficiency from work-load balancing policies in the software to dynamic voltage and frequency scaling, but multi-core microprocessors complicate any kind of operating point response as each core will be unique. Designing circuits that function as integrated sensors which can be used to select the correct operating point is the topic of this talk. Included are sensors that measure temperature, voltage, process variation, timing margin, and other noise processes. With these integrated sensors incorporated into an appropriate feedback loop, the data needed can be provided to increase the efficiency of microprocessors, or of any integrated circuit.

Bio: Alan Drake received his B.S. degree from

May 18 - May 20, 2009, Freescale Semiconductor, Austin, TX, U.S.A.; <a href="http://www.ICICDT.org">http://www.ICICDT.org</a>

the University of Arizona and his M.S. and Ph.D. degrees from the University of Michigan, all in Electrical Engineering. In 2004 he joined the research staff at IBM's Austin Research Lab. His research is focused on low-power circuit design and integrated timing sensors. Included in this is work on using resonant clocking to reduce local clock power, adaptive body-biasing techniques for SOI circuits, and more recently designing critical path monitors to provide feedback to dynamic voltage and frequency scaling systems.

03: 45 p.m. 04:00 p.m.

Coffee Break
Mixed-Voltage I/O Circuits and ESD
Protection Design in CMOS ICs

**Presenter:** Prof. Morris (Ming-Dou) Ker, I-Shou University, Kaohsiung, Taiwan

Abstract: To improve circuit operating speed and performance, the device dimension of MOSFET has been shrunk in the advanced CMOS integrated circuits (ICs). With the scaled-down device dimension and thin gate oxide in the advanced nanoscale CMOS technology, the power supply voltage of normal circuit operation is also scaled down to reduce the power consumption and to meet the gateoxide reliability. However, microelectronic systems nowadays still consist of the semiconductor chips fabricated in different CMOS technologies. Therefore, the microelectronic systems often require the I/O interface circuits between semiconductor chips or sub-systems which have different power supply voltages. With the different power supply voltages in a microelectronic system, chip-to-chip I/O circuits must be designed to avoid electrical overstress across the gate oxide, to avoid hot-carrier degradation on the output devices, and to prevent the undesired leakage current paths between the chips. Therefore, some advanced mixed-voltage I/O circuits had been developed to handle the I/O signals of higher voltage level but only realized with low-voltage CMOS devices.

Besides the different voltage levels of I/O signals in the mixed-voltage I/O circuits, such mixed-voltage I/O circuits connected to the bonding pad in CMOS ICs are still requested to meet the electrostatic discharge (ESD) specifications in IC industry. For safe production of CMOS ICs, the ESD robustness

for commercial IC products was traditionally requested to sustain ESD levels of  $\pm 2kV$  in the test standard of Human Body Model (HBM). How to design the on-chip ESD protection circuits to effectively protect the mixed-voltage I/O circuits realized by the nanoscale CMOS devices with thin gate oxide is a quite difficult challenge. Such on-chip ESD protection circuits for mixed-voltage I/O circuits should meet the gate-oxide reliability constraints and prevent the undesired leakage current paths during normal circuit operating condition. Under ESD zapping condition, the ESD protection circuit should be quickly triggered on to discharge ESD current.

In this Tutorial, the design of mixed-voltage I/O circuits realized with low-voltage CMOS devices is introduced, and then the on-chip ESD protection design for mixed-voltage I/O circuits without using the additional thick gateoxide process is presented. Some advanced ESD protection designs by using high-voltagetolerant power-rail ESD clamp circuits to protect mixed-voltage I/O circuits will be demonstrated with silicon verification in nanoscale CMOS technology. ESD protection for CMOS ICs is not only the process issue but also highly dependent to the design issue. Mixed-voltage I/O circuits and corresponding ESD protection designs have become important reliability design issues in nanoscale CMOS IC products, wherefore the circuit designers need to watch.

Morris (Ming-Dou) Ker received the Ph.D. degree from the Institute of Electronics, National Chiao-Tung University, Hsinchu, Taiwan, in 1993. He was ever worked as the Department Manager in the VLSI Design Division of the Computer and Communication Research Laboratories (CCL), Industrial Technology Research Institute (ITRI), Taiwan. Since 2004, he has been a Full Professor in the Department of Electronics Engineering, National Chiao-Tung University, Taiwan. He also served as the Director of Master Degree Program in the College of Electrical Engineering and Computer Science, National Chiao-Tung University; as well as the Associate Executive Director of National Science and Technology Program on Systemon-Chip (NSoC), Taiwan. In 2008, he was rotated to I-Shou University, Kaohsiung, Taiwan, as Chair Professor and Vice President. In the field of reliability and quality design for

May 18 - May 20, 2009, Freescale Semiconductor, Austin, TX, U.S.A.; http://www.ICICDT.org

circuits and systems in CMOS technology, he has published over 360 technical papers in international journals and conferences. He has proposed many inventions to improve reliability and quality of integrated circuits, which have been granted with 138 U.S. patents and 144 Taiwan patents. His current research interests include reliability and quality design for nanoelectronics and gigascale systems, high-speed and mixed-voltage I/O interface circuits, on-glass circuits for system-on-panel applications, and biomimetic circuits and systems for intelligent prosthesis. Prof. Ker had been invited to teach or to consult reliability and quality design for integrated circuits by hundreds of design houses and semiconductor companies in the worldwide IC Industry.

Prof. Ker has served as member of the Technical Program Committee and Session Chair of numerous international conferences. He was selected as the Distinguished Lecturers in IEEE Circuits and Systems Society for 2006-2007, as well as, in IEEE Electron Devices Society for 2008-2009. He ever served as Associate Editor in IEEE Trans. on VLSI Systems. He was the President of Foundation in Taiwan ESD Association. In 2008, Prof. Ker was elevated as an IEEE Fellow with the citation of "for contributions to electrostatic protection in integrated circuits, performance optimization of VLSI microsystems". In 2009, Prof. Ker was awarded as one of the top ten Distinguished Inventors in Taiwan, and also selected as one of top hundred Distinguished Inventors in China.

05: 15 p.m. **Adjourn** 

May 19 - May 20, 2009, Freescale Semiconductor, Austin, TX, U.S.A.; http://www.ICICDT.org

### Plenary & Workshop Sessions May 19 – May 20, 2009

May 19 - May 20, 2009						
	May 19, 2009	,	Chua Chin Wang, National Sun Yat-Sen University, Taiwan.			
08:00 a.m. 08:30 a.m.	Registration & Breakfast (Included) Opening Remarks: Koji Eriguchi, Kyoto University, Conference Chair,	11: 00 a.m.	Invited Paper: Low-Leakage Electrostatic Discharge Protection Circuit in 65-nm Fully- Silicided CMOS Technology, Prof. Ming-Dou (Morris) Ker et al., Taiwan			
08:40 a.m.	Keynote Speech: A Sub 2W Low Power IA Processor for Mobile Internet Devices in 45nm Hi-K Metal Gate CMOS, Gianfranco Gerosa, Sr. PE, Intel, USA	11:10 a.m.	Invited Paper: ESD+RFIC Co-Design: Methodology, Optimization and Examples, Prof. Albert Wang, UC Riverside, USA			
Session A:	Low Power	11:20 a.m.	A 0.9 V to 5 V Mixed-Voltage I/O Buffer Using NMOS Clamping Technique, Prof. Chua-Chin Wang, Jen-Wei Liu, Ron-Chi Kuo,			
Co-Chairs	Toshinari Takayanagi, Apple, USA & Geoffrey Yeap, Qualcomm, USA.		National Sun Yat-Sen University, Taiwan			
09:30 a.m.	Invited: Custom Design in Low-Power/High-Performance ASIC World, Ty Garibay, Richard Reis, TI, USA	Session C: Co-chairs:	Jan Ackaert, On Semiconductor, Belgium &			
09:40 a.m.	LLA: A Low-Latency Asynchronous Pipeline Control Circuit, Morteza Gholipour Geshnyani, Mehrdad Nourani, Ali Afzali-	11:30 a.m.	Thuy Dao, Freescale Semiconductor, USA Invited Paper: Recent Advances in RF- LDMOS High Power IC Development, Wayne Burger, Freescale Semiconductor, USA			
09:50 a.m.	Kusha, Azad University of Behshahr, Iran  A Low-Power and Multi-Mode Design  Approach for Reconfigurable MASH SDM,  Hsin-Liang Chen and Jen-Shiun Chiang,	11:40 a.m.	Through Silicon Via Stress Characterization, Thuy Dao, Dina H. Triyoso, Mike Petras, Freescale Semiconductor, and Michael Canonico, USA			
10:00 a.m.	Tamkang University, Taiwan  Invited: Implementation and Evaluation of Fine-grain Run-time Power Gating for a  Multiplier, Kimiyoshi Usami, Mitsutaka	11:50 a.m.	A 30V Complementary Bipolar Technology for xDSL Line Drivers, J. Speyer, Thomas J. Krutsick, and John K. Moriarty, Zarlink Semiconductor, USA.			
	Nakata, Toshiaki Shirai, Seidai Takeda <sup>2</sup> ,Naomi Seki <sup>1</sup> , Hideharu Amano <sup>1</sup> and Hiroshi Nakamura <sup>2</sup> , Shibaura Institute of Technology, <sup>1</sup> Keio University, <sup>2</sup> The University of Tokyo, Japan	12:00p.m. – 0 01:00p.m. – 0	• • •			
10:10 a.m.	Improvement of LDO's PSRR Deteriorated	<b>Session D:</b>				
	By Reducing Power Consumption: Implementation and Experimental Results,	Co-chairs:	Ruchir Purir, IBM, USA & David Pan, UT of Austin, USA			
10,20 a m	Socheat HENG, Cong-Kha PHAM, UEC, Japan	02:10 p.m.	Cell Merge: A Basic-Pre-Clustering Clustering Algorithm for Placement, X. Zhang, T. Takeuchi, M. Koyonaga, Kochi			
10:20 a.m.	Asynchronous Dual-Mode Buck Converter Design with Protection Circuits for Battery Applications, Jefferson A. Hora, Jiun-Chang Zeng, and Wan-Rone Liou, National Taipei	02:20 p.m.	Univ, Japan  AKEBONO: A Novel Quick Incremental  Placer, X. Zhang, T. Takeuchi, M. Koyonaga,			
10:30 a.m.	University, Taiwan  Large Random Telegraph Noise in Sub- Threshold Operation of Nano-Scale	02:30 p.m.	Kochi Univ, Japan  Applications of Network Coding in Global Routing. N. Nemade, A. Spritson, J. Hu, Texas			
	nMOSFETs, J.P. Campbell, L.C. Yu, K.P. Cheung, J. Qin, J.S. Suehle, A. Oates, K. Sheng, National Institute of Standards and Technology, USA	02:40 p.m.	A&M Univ, TX  Timing Analysis of Dual-Edge-Triggered Flip-Flop Based Circuits with Clock Gating, Chungki Oh, Sangmin Kim, and Youngsoo			
10:40 a.m. –	11:00 a.m. Coffee Break	02:50 p.m.	Shin, KAIST, Korea Timing yield estimation with clock network			
Session B:	ESD		correlations by propagating discrete probability distributions, L.Yu, C. Shin, J.			

Morris Ker, I-Shou University, Taiwan. &

Co-Chairs

probability distributions, L.Yu, C. Shin, J.

# International Conference on IC Design & Technology May 19 – May 20, 2009, Freescale Semiconductor, Austin, TX, U.S.A.; <a href="http://www.ICICDT.org">http://www.ICICDT.org</a>

	, , , , , , , , , , , , , , , , , , , ,	, ,	, e.e.i., <u>intpi//www.ieresbriorg</u>		
03:00 p.m. 03:10 p.m.	Liou , Y. Shin, KAIST Korea, National Tsing Hua Univ, Taiwan  Network Flow Based BSM Asssignment, Hua Xiang, Haoxing Ren, Tingdong Zhou, IBM  A Simple Fast Exact Density Calculation Algorithm, Hua Xiang, C. Chiu, R. Puri, IBM, Iowa State Univ, IA.	4:45 p.m. 5:05 p.m.	Invited: Combined Altitude and Underground Real-Time SER Characterization of CMOS Technologies on the ASTEP-LSM Platform  J.L. Autran, P. Roche, S. Sauze, G. Gasiot, D. Munteanu, P. Loaiza, M. Zampaolo and J. Borel, Aix-Marseille University, France  A 2.5 GHz Radiation Hard Fully Self-biased		
03:20 a.m. –	•	5.05 p.m.	PLL using 0.25 μm SOS-CMOS technology,		
Co-chairs:	PID/high K Koji Eriguchi, Kyoto University, Japan & Kin P. (Charles) Cheung, National Institute of Standards & Technology, USA.	5:15 p.m.	Partha Pratim Ghosh, E. Xiao, University of Texas at Arlington, Arlington, TX, USA Soft Error Estimates for Fabless Companies, Anand Dixit, Raymond Heald, Sun Microsystems, Santa Clara, CA, USA		
03:35 p.m.	Invited Paper: The Negative Bias Temperature Instability vs. High-Field Stress Paradigm, J.P. Campbell <sup>1</sup> , K.P.	05:30 p.m. –	·		
	Cheung <sup>1</sup> , J.S. Suehle1, and A.S. Oates <sup>2</sup> , <sup>1</sup> National Institute of Standards and	06:30 p.m. –	07:00 p.m. Reception		
03:45 p.m.	Technology, USA, TSMC Ltd., Taiwan  Invited Paper: Unified TDDB Model for Stacked High-k Dielectrics - Byoung Hun Lee, Gwangju Institute of Science and		on Marc Belleville, CEA, France 8:00pm		
03:55 p.m.	Technology, Korea  Factors impacting stabilization of tetragonal		May 20, 2009		
03.33 p.m.	phase in HfxZr1-xO2 high-k dielectrics, D.H. Triyoso, R.I. Hegde, R. Gregory, G. Spencer, J.K. Schaeffer, and M. Raymond, Freescale Semiconductor, USA	08:00 a.m. 08:30 a.m. 08:40 a.m.	Registration & Breakfast (Included) Opening remarks & announcements Keynote Speech: QorIQ P4080		
04:05 p.m.	Impact of Gate-Oxide Breakdown on Power-Gated SRAM, Hao-I Yang, Ching-Te Chuang, and Wei Hwang, National Chiao-Tung University, Hsinchu, Taiwan		Communications Processor Design in 45nm SOI, Greg Bartlett, VP, Design Technology, Freescale Semiconductor, USA		
04:15 p.m.	Simulation and Experimental Study on the Characteristics of Plasma-Induced Damage and Methodology for Accurate Damage Analysis, Matsuda, Asahiko, Yoshinori	Session G: Co-chairs:	Aurangzeb Khan, Everspin Technologies, USA & Dac Pham, Freescale Semiconductor, USA.		
	Nakakubo, Riki Ogino, Hiroaki Ohta, Koji Eriguchi, and Kouichi Ono, Kyoto University, Kyoto, Japan	09:30 a.m.	Invited Paper: A Low-Power Multi-Core Media Co-Processor for Mobile Application Processors, Shuou Nomura, Fumihiko		
04:25 p.m.	Study of Plasma-Induced "Si Recess Structure" and Its Effects on Threshold Voltage Variability in Advanced MOSFETs, Koji Eriguchi, Asahiko Matsuda, Yoshinori Nakakubo, Masayuki Kamei,		Tachibana, Tetsuya Fujita, Chen Kong Teh, Hiroyuki Usui, Fumiyuki Yamane, Yukimasa Miyamoto, Takahiro Yamashita, Hiroyuki Hara, Mototsugu Hamada, Yoshiro Tsuboi, Toshiba Corporation, Kawasaki, Japan		
	Hiroaki Ohta, and Kouichi Ono, Kyoto University, Kyoto, Japan	09:40 a.m.	Implementation of area efficient H.264/AVC CAVLC Decoder, Byung-Sik Choi, Jong-Yeol Lee, Chonbuk University, South Korea.		
Session F: Co-chairs: 4:35 p.m.	SER Eishi Ibe, Hitachi, Japan Invited: SEE Characterization and Mitigation in Ultra-Deep Submicron Technologies, David G. Mavis, Paul H. Eaton, and Michael D. Sibley, Microelectronics	09:50 a.m.	Implementation of Scalable Interconnect Networks for data reordering used in Discrete Trigonometric Transforms (DTT), Adel Hussein, Adnan Suleiman, Nabil Kerkiz1, David Akopian, UTSA, USA, <sup>1</sup> Intel Corporation, Austin, TX, USA		
	Research Development Corporation, New Mexico, USA	10:00 a.m.	Semi-Custom Design Flow: Leveraging Place and Route Tools in Custom Circuit Design,		

May 19 – May 20, 2009, Freescale Semiconductor, Austin, TX, U.S.A.; <a href="http://www.ICICDT.org">http://www.ICICDT.org</a>

10:10 a.m.	Nadeem N. Eleyan, Ken Lin, Masud Kamal, Baker Mohammad, Paul Bassett, Qualcomm, Austin, TX, USA.  Invited Paper: Technology and Design Aspects of Ultra-Thin Silicon Chips for Bendable Electronics, Harald Richter, Horst Rempp, Joachim Burghartz, Mahadi-Ul Hassan, Christine Harendt, Nicoleta Wacker, Martin Zimmermann, Institute for Microelectronics, Stuttgart, Germany.		Perrine BATUDE, Alexandre VALENTIAN, CEA, France  Operation of Multi-Level Phase Change Memory Using Various Programming Techniques, Jun-Tin Lin, Yi-Bo Liao, Meng-Hsueh Chiang, and Wei-Chou Hsu, National Ilan University, Taiwan  01:00 p.m. Lunch  2:00 p.m. Workshops G, H, I
10:20 a.m. – 10:35 a.m. <b>Coffee Break</b>		-	•
	Advance Transistors	Session J: Co-chairs:	DFM/DFT/DFR/DFY Tanay Karnik, Intel, USA & Rouwaida Kanj, IBM, USA
Co-Chairs	Bich Yen Nguyen, Soitec, USA & Dong-won Kim, Samsung, South Korea	02:00 p.m.	Invited Paper: An On-Chip Process Control Monitor for Process Variability
10:35 a.m.	Invited Paper: Jason Woo, UCLA, USA		Measurements in Nanometer Technologies,
10:45 a.m.	Systematic Approach of FinFET based SRAM Bitcell Design for 32nm Node and		Fabian Klass, Ashish Jain, and Greg Hess,
	Below, S. C. Song, M. Abu-Rahma, B. M.		Apple Inc., Cupertino, CA
	Han, L. Ge, S. S. Yoon, J. Wang, W. Yang1, D.	02:10 p.m.	Invited Paper: Statistical-Aware Designs for
	Liu1, C. Hu1, and G. Yeap, Qualcomm, USA		the nm Era, Rajiv Joshi <sup>1</sup> and Rouwaida Kanj <sup>2</sup> , IBM. <sup>1</sup> IBM TJ Watson Research Center,
10:55 a.m.	Stacked 3-Dimensional 6T SRAM Cell with		Yorktown Heights, NY, <sup>2</sup> IBM Austin Research
	Independent Double Gate transistors, Marcus Weis, Andrzej Pfitzner, Dominik		Labs, Austin, TX.
	Kasprowicz, Rainer Emling, Thomas Fischer,	02:20 p.m.	Dynamic Cache Resizing Architecture for
	Stephan Henzler, Wojciech Maly and Doris		High Yield SOC, Baker Mohammad <sup>1</sup> , Muhammad Tauseef Rab <sup>1,3</sup> , Khadir
	Schmitt-Landsiedel, Technical University		Mohammad <sup>2</sup> , and M. Aater Suleman <sup>3</sup>
11:05 a.m.	Munich, Germany <b>Dynamic Power Analysis for Custom</b>		<sup>1</sup> Qualcomm Incorporated, <sup>2</sup> University of Texas
11.03 a.m.	Designs, Stephen Bijansky, Bassam Mohd,		at San Antonio, San Antonio, TX, <sup>3</sup> University
	and Baker Mohammad, Qualcomm, USA	02.20	of Texas at Austin, Austin, TX.
11:15 a.m.	A Novel Poly-Si Thin-Film Transistor with	02:30 p.m.	An Innovative Timing Slack Monitor for Variation Tolerant Circuits, B. Rebaud <sup>1</sup> , M.
	Multi-Trenched Body by Using Isotropic-		Belleville <sup>1</sup> , E. Beigné <sup>1</sup> , M. Robert <sup>2</sup> , P.
	etching for Suppressing Off-State Leakage, Hsien-Nan Chiu, Jyi-Tsong Lin, Yi-Chuen Eng,		Maurine <sup>2</sup> , and N. Azemard <sup>2</sup> . <sup>1</sup> CEA, LETI,
	Po-Hiesh Lin, Tzu-Feng Chang, Chih-Hung		MINATEC, Grenoble, France, <sup>2</sup> LIRMM -
	Sun, Chih-Hao Kuo and Hsuan-Hsu Chen,		CNRS - Université Montpellier II, Montpellier,
	Department of Electrical Engineering/National	02:40 p.m.	France.  Machine Learning based Lithographic
	Sun Yat-Sen University, Taiwan	02.40 p.III.	Hotspot Detection with Critical Feature
Session I:	Memory		Extraction and Classification, Duo Ding,
Co-chairs:	Hideto Hidaka, Renesas, Japan & Susumu		Xiang Wu, Joydeep Ghosh, and David Z. Pan
Co <b>Chan</b> s.	Shuto, Toshiba, Japan.		University of Texas at Austin, Austin, TX.
11:25 a.m.	Invited Paper: Embedded Non-Volatile	Session K:	<b>Emerging Technology</b>
	Memory Technologies, Kelly Baker, Freescale	Co-chairs:	Simon Deleonibus, CEA, France
11:35 a.m.	Semiconductor, USA  Robust Multi-VT 4T SRAM Cell in 45nm	2:50 p.m.	Invited: Semiconductor Nanowires: From
11.55 a.m.	Thin BOx Fully-Depleted SOI technology		Science to Technology, Ali Javey, UC Berkeley, USA
	with Ground Plane, JP. Noel, O. Thomas, C.	3:00 p.m.	Invited: High K impact on device
	Fenouillet-Beranger, MA. Jaud and A. Amara,	5.00 p.m.	performance and Reliability, Jack Lee, UT
11.45 0	CEA LETI, France		Austin , USA
11:45 a.m.	Compact 6T SRAM cell with robust Read/Write stabilizing design in 45nm	3:10 p.m.	One-transistor bistable-body tunnel SRAM,
	Monolithic 3D IC technology, Olivier		K. Karda, J. Brockman, S. Sutar, and A. Seabaugh, ND
	THOMAS, Maud VINET, Olivier ROZEAU,		200000000000000000000000000000000000000

May 19 - May 20, 2009, Freescale Semiconductor, Austin, TX, U.S.A.; http://www.ICICDT.org

3:20 p.m. Complementary Nano-Electro-Mechanical Switches For Ultra-Low-Power Applications: Fabrication, Design and Simulation, Khawla Alzoubi, Daniel G. Saab, and Massood Tabib-Azar, CWRU

3:30 p.m. - 3:45 p.m. **Coffee Break** 

Session 1	L:	RF/	<b>Analog</b>

Co-Chairs Didier Berlot, STMicroelectronic, France & Marc Belleville, CEA, France

3:45 p.m. Design of a monolithic width programmable gaussian monocycle pulse generator for ultra wideband radar in cmos technology, Olivier Lemaire, Tian Xia University of Vermont, United States of America

3:55 p.m. A 1.8V 200mW 8-bit 1GSPS CMOS A/D Converter with a Cascaded-Folding and an Interpolation, Jooho Hwang, Dongheon Lee, Sunghyun Park, Junho Moon, and Minkyu Song, Dongguk University, Seoul Korea

4:05 p.m. An 8-bit 500MHz Two-Step ADC in 0.13-um SiGe BiCMOS, Po-Hsin Chen and Martin Peckerar, University of Maryland, Taiwan

4:15 p.m. A 10-bit 310μW 2MSPS Charge Redistributed D/A Converter, Hyukbin Kwon, Hyosang Kim, Seunghoon Kim, Junho Moon, and Minkyu Song, Dongguk University, Korea

4:25 p.m. Investigating the Linearity of MOSFET-only Switched-capacitor Delta-sigma Modulators Under Low-voltage Condition, Farhad Alibeygi Parsan, Ahmad Ayatollahi, Adib Abrishamifar, Iran

4:35 p.m. Closing Remarks

4:50 p.m. – 5:50 p.m. **Workshops J, K, L** 5:50 p.m. **Adjourn**